## 0/593812 IAP9/Rec'd PCTVPTO 22 SEP 2006

DOCKET NO.: 296483US0PCT

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Kouji NISHIKAWA, et al.

SERIAL NO.: NEW U.S. PCT APPLICATION

FILED: HEREWITH

INTERNATIONAL APPLICATION NO.: PCT/JP05/05398

INTERNATIONAL FILING DATE: March 24, 2005

FOR: POSITIVELY RADIATION-SENSITIVE RESIN COMPOSITION

## **REQUEST FOR PRIORITY UNDER 35 U.S.C. 119** AND THE INTERNATIONAL CONVENTION

Commissioner for Patents Alexandria, Virginia 22313

Sir:

In the matter of the above-identified application for patent, notice is hereby given that the applicant claims as priority:

**COUNTRY** 

APPLICATION NO

DAY/MONTH/YEAR

2004-087520 Japan

24 March 2004

Certified copies of the corresponding Convention application(s) were submitted to the International Bureau in PCT Application No. PCT/JP05/05398. Receipt of the certified copy(s) by the International Bureau in a timely manner under PCT Rule 17.1(a) has been acknowledged as evidenced by the attached PCT/IB/304.

> Respectfully submitted, OBLON, SPIVAK, McCLELLAND,

MAIER & NEUSTADT, P.C.

Customer Number

22850

(703) 413-3000 Fax No. (703) 413-2220 (OSMMN 08/03)

Norman F. Oblon Attorney of Record Registration No. 24,618 Surinder Sachar

Registration No. 34,423